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Ms. Ri Hu Hwang is a patent attorney in the Intellectual Property Practice Group at Shin & Kim, where her primary areas of practice include the filing and prosecution of patents related to displays, electronics, and information and communications technology (ICT).

She previously worked at a patent law firm, where she handled domestic and international patent applications in the electronics and IT fields, responded to office actions, and managed PCT international applications.

経歴

2026-Present	Shin & Kim LLC
2025-2026	DANA Patent & Law Firm

学歴

2010-2017	Yonsei University (B.S. in Physics)
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資格

2024	Admitted to patent bar, Korea
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言語

Korean, English

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